



IFW

Docket No.: 005882.P060

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Choong Yong Sohn, et al

Application No.: 10/679,021

Filed: October 2, 2003

For: **METHOD OF FORMING A BUFFER  
DIELECTRIC LAYER IN A  
SEMICONDUCTOR DEVICE AND A  
METHOD OF MANUFACTURING A  
THIN FILM TRANSISTOR USING  
THE SAME**

Art Group: 2812

Examiner: Luk, Olivia T.

**PETITION FOR EXTENSION OF TIME AND  
AMENDMENT AND RESPONSE TO OFFICE ACTION**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir or Madam:

In response to the Office Action dated February 4, 2005, Applicant submits the following amendments and remarks:

06/03/2005 WASFAW1 00000013 10679021

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